

Residual Statement

In the following we state, if according to our knowledge any substance(s) classified as 'Residual Solvent(s)' is/are used in the manufacture and/or purification of:

Product: HEXANOIC ACID NATURAL

- None of the solvents classified 'Residual Solvents' in the Current USP <467> and the ICH Q3C guideline are used. The absence of such solvents as impurities in the above mentioned product is confirmed.
- One or more of the solvents classified as 'Class 1 Residual Solvents' in the Current USP <467>and the ICH Q3C guideline are used. The compliance of limited values of such solvents as impurities in the above mentioned product in accordance with the Current USP <467>and the ICH Q3C guideline is confirmed.
- One or more of the solvents classified as 'Class 2 Residual Solvents' in the Current USP <467>and the ICH Q3C guideline are used. The compliance of limited values of such solvents as impurities in the above mentioned product in accordance with the Current USP <467>and the ICH Q3C guideline is confirmed.
- One or more of the solvents classified as 'Class 3 Residual Solvents' in the Current USP <467>and the ICH Q3C guideline are used. The compliance of limited values of such solvents as impurities in the above mentioned product in accordance with the Current USP <467>and the ICH Q3C guideline is confirmed.
- One or more of the solvents listed under **Table 4** in the Current USP <467>and the ICH Q3C guideline are used.

If 2, 3, 4 or 5 are applicable, please find the details in the table below:

| Solvent | Class | USP <467>and the ICH Q3C | Please fill this column Amount |
|---------|-------|---------------------------|--------------------------------|
| | | Specification Limit (ppm) | present in materials (ppm) |
| n.a | n.a | n.a | n.a |

Authorized Signature: Name: Chelsea Chen

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